

Effect of rapid thermal annealing in vacuum on the structural and optical properties of MoS₂ flakes in solution

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Abstract

Recently, top-down and bottom-up methods have been developed to fabricate single-layer (1L) MoS₂ nanosheets. The top-down method focuses on the mechanical [1-2] and solution-based exfoliation [3-4] of bulk MoS₂ crystals. Although the mechanical exfoliation of MoS₂ can produce the pristine 1L MoS₂ with high quality, its yield and reproducibility are low. The solution-based exfoliated MoS₂ is often accompanied by residual chemicals from the solution used, which in turn affects the properties of MoS₂ nanosheets [3]. In the previous studies, a thermal annealing method has been used in layer thinning and etching of mechanically exfoliated MoS₂ for achieving single-layer MoS₂ from multi-layer MoS₂ [1]. In this work, MoS₂ flakes of ~ 400 nm lateral size in ethanol solution were used to investigate the thermal annealing mechanism of MoS₂ flakes. For single-layer MoS₂ nanosheets, MoS₂ flakes solution was dropped on the whole surface of 100 nm SiO₂ substrate and subsequently, MoS₂ flakes were heated by rapid thermal annealing at various temperatures from 100 to 500 °C under vacuum for 10 min. The annealed samples were characterized by optical microscopy, Raman spectroscopy, and atomic force microscopy (AFM). Fig. 1 shows the optical images of MoS₂ nanosheets on 100 nm SiO₂/Si, in which different color contrast represents different layer thickness of MoS₂. [5] Fig. 1 (a) shows the MoS₂ flakes before thermal annealing, which consists mainly of 6L nanosheets. Subsequently, thermal annealing was performed at 200 °C for 10 min. The formation of 2L MoS₂ nanosheet by thinning was observed after thermal annealing, as shown in Fig 1 (b). Raman spectra of the transferred layers exhibited two intense features, E_{2g}¹ and A_{1g} peaks at ~ 384 and ~ 403 cm⁻¹, respectively, uniquely characteristic of MoS₂ film. The two Raman modes, E_{2g}¹ and A_{1g}, exhibited sensitive thickness dependences, with the frequency of the former decreasing and that of the latter increasing with thickness [6]. The annealing behaviors show several intriguing characteristics. Most strikingly, we find that the E_{2g}¹ vibration softens (blue shifts), while the A_{1g} vibration stiffens (red shifts) with increasing annealing temperature, as shown in Fig 2. This Raman analysis reveals optimum annealing temperature of 200 °C for the synthesis of smallest-layer-number and best-quality MoS₂. The thickness of MoS₂ estimated by AFM was consistent with the Raman results. As a result of thermal annealing, the MoS₂ nanosheet is thinned, possibly due to its oxidation to form MoO₃. Possible mechanisms are proposed to explain the formation processes of MoS₂ nanosheets from MoS₂ flakes during the annealing.

References

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Figures

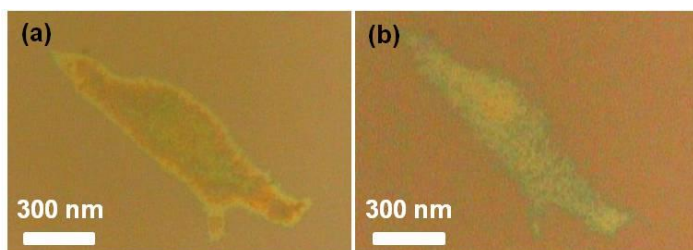


Fig. 1. Optical images of MoS₂ flakes before (a) and after (b) thermal annealing in vacuum for 10 min at 200 °C

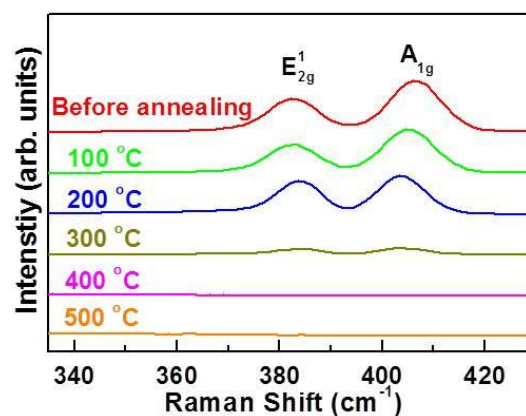


Fig. 2. Raman spectra of MoS₂ flakes for various annealing temperatures together with the spectrum before thermal annealing